

REMARKS

Claim 34 has been amended to claim the advantageous arrangement shown, for example, in Figures 2, 3, and 4 of the present application. Note that the material 22, which is deposited, not only fills the openings 12, shown in Figure 1, but also flows underneath the central portion between the openings in Figure 2.

This is the result, in some embodiments, of the gap between the mask 10 and the underlying device 18. Maintaining such a gap is set forth in new claim 39.

None of the references show a method in which material is deposited so that it enters the openings in a stencil plate and extends under the central portion of the plate. In some embodiments, a U-shaped contact surface results, as shown in Figure 4, which achieves multipoint contact.

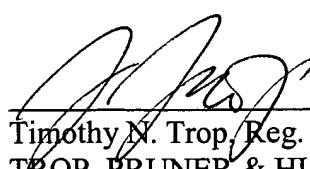
Therefore, the claims as amended should patentably distinguish over the art of record.

Reconsideration of the finality of the rejection is respectfully requested. While the claims were amended, the claims were only amended in the preamble portions of the claim. Thus, it should not have changed the scope or nature of the search.

Thus, since the amendments did not necessitate new grounds of rejection, the present amendment should be entered.

In view of these remarks, favorable reconsideration is respectfully requested.

Respectfully submitted,



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